

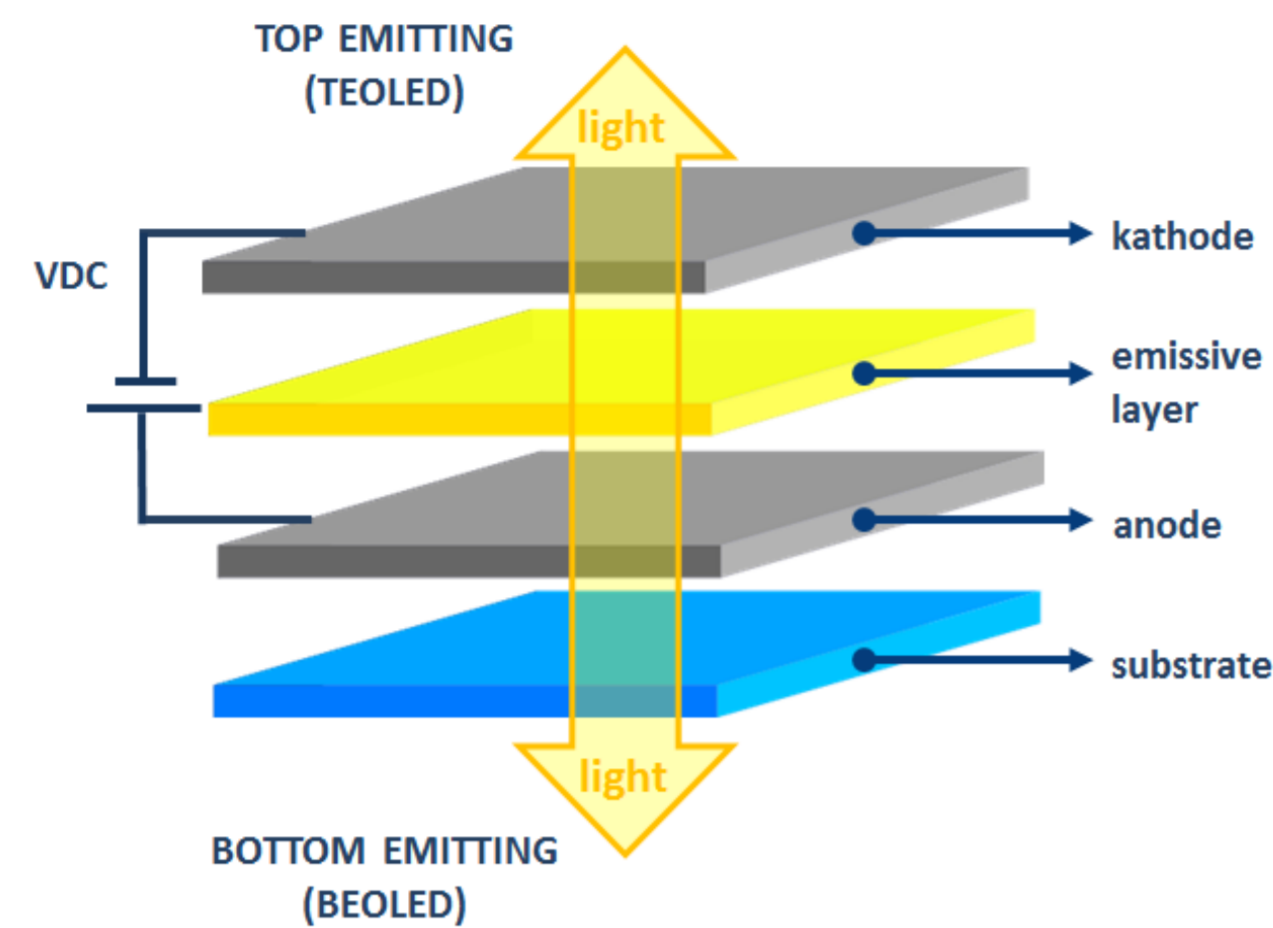
# ITO-free transparent top electrode for top emitting OLEDs

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## Introduction

### Structure Organic Light Emitting Diode (OLED)



### Problems with Indium Thin Oxide (ITO) [1]

ITO

- Expensive
- Crack formation
- Can not be a top electrode

### Alternatives

Semi-transparent thin metal layers [2]



Metal grids [3]

## Experimental

### Au layers

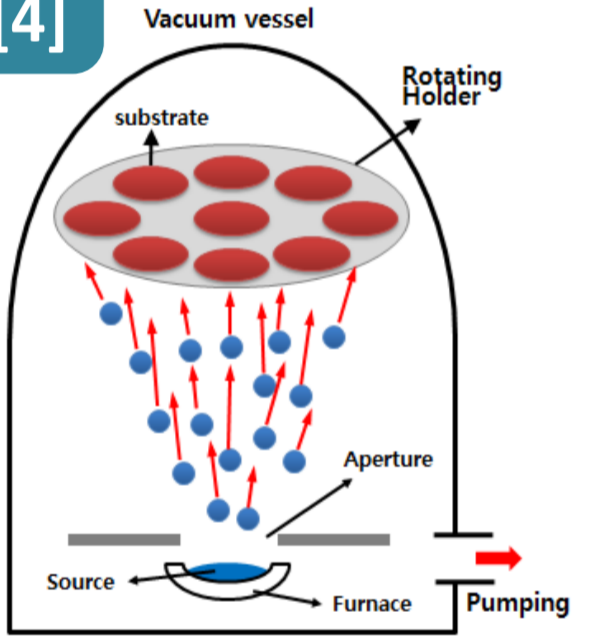


Layer thickness: 1; 2,5; 5; 7,5; 10; 15 nm

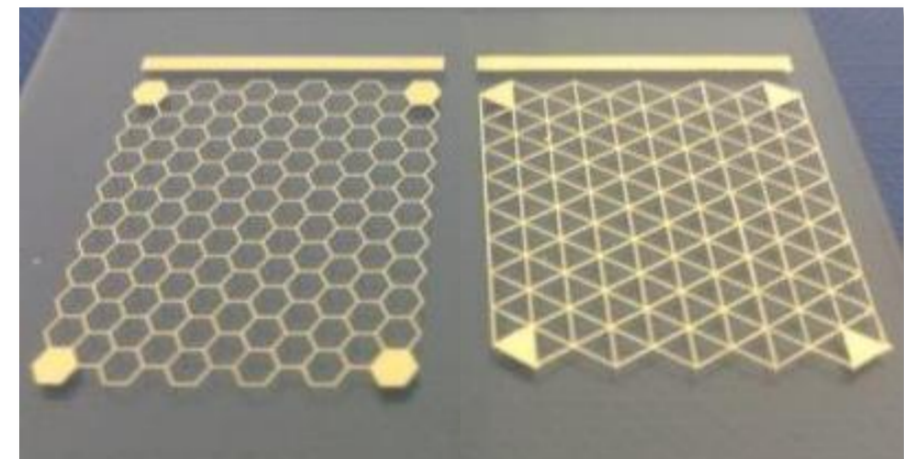
Dimensions:  
20 mm by 25 mm

On glass substrates

Thermal evaporation [4]



### Ag grids

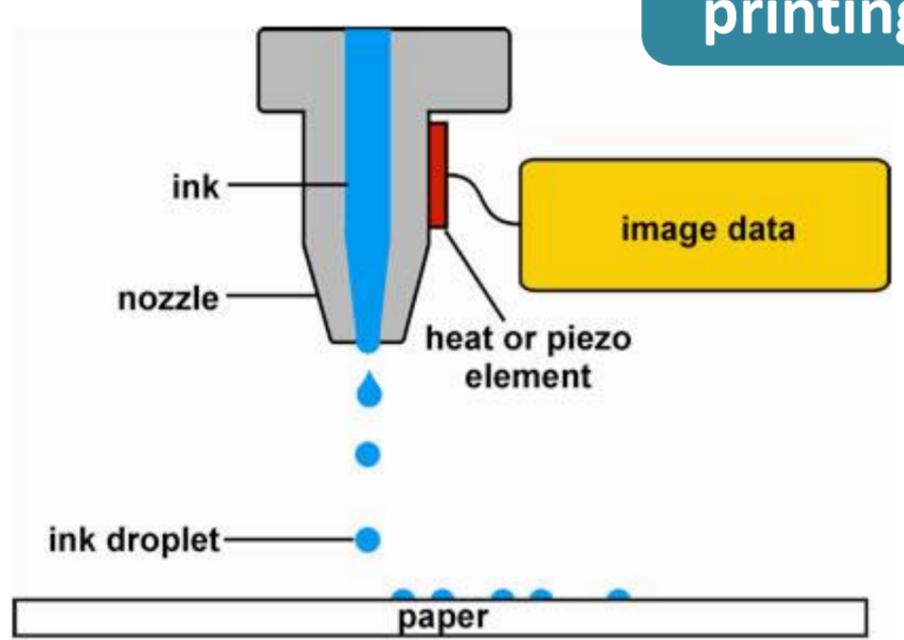


Layers thickness: 150-250 nm

Dimensions:  
Hex and tri:  $r_{\text{outer circle}} = 0,87-1,25$  mm  
Line: thickness 10 nm, line spacing of 150-240 nm

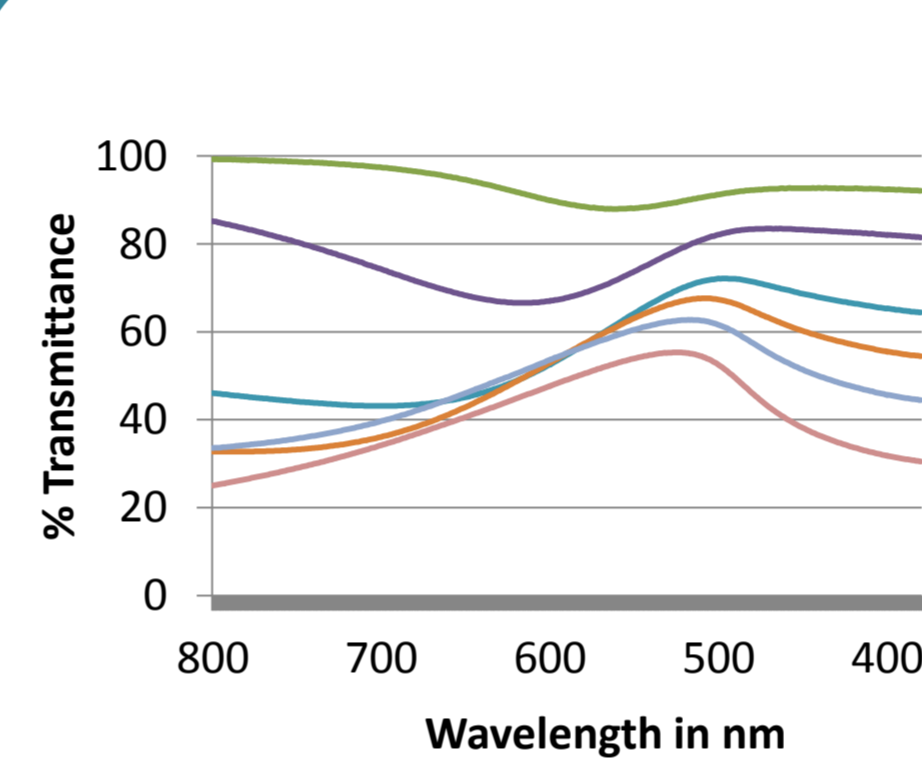
On glass substrates

Ink jet printing [5]

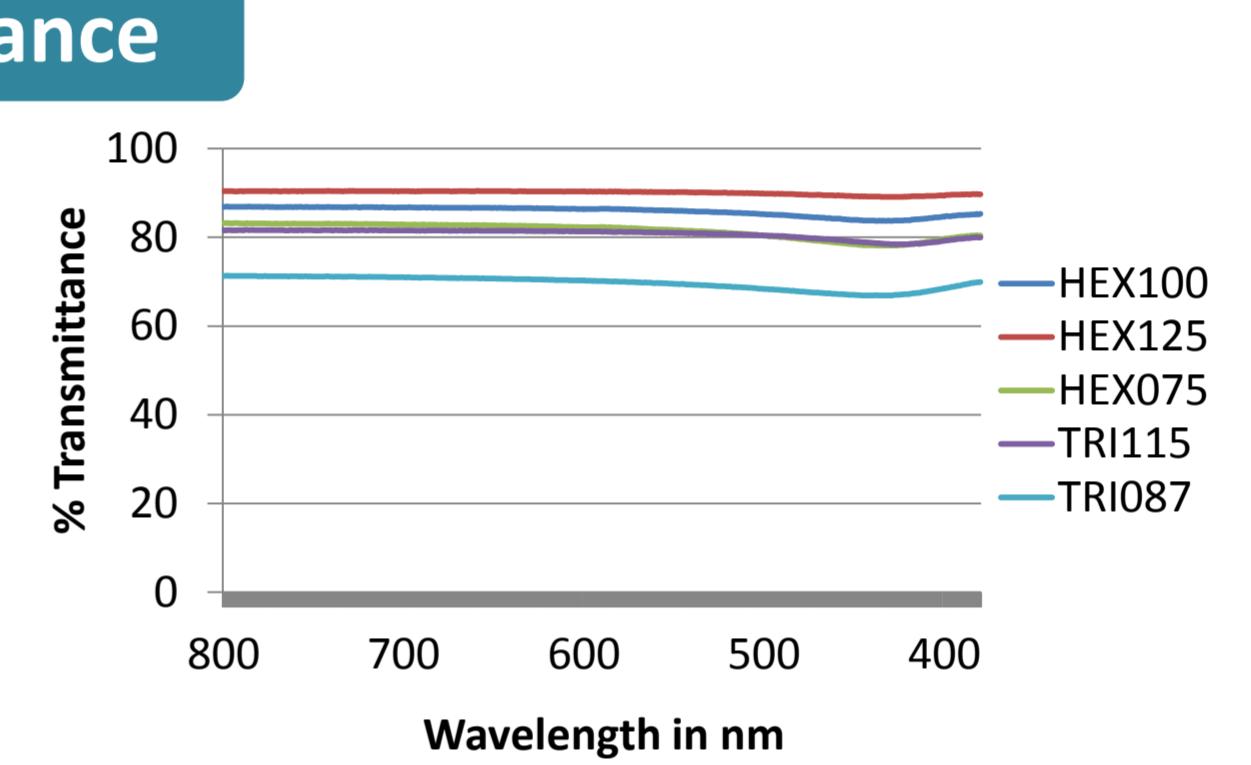


## Results

### Au layers



### Ag grids



### Conductivity

Au thickness	$R_s$ ( $\Omega/\square$ )
Au 1nm	> 20 M
Au 2,5nm	> 20 M
Au 5nm	> 20 M
Au 7,5nm	123,7
Au 10nm	11,5
Au 15nm	3,2

Ag grid pattern	$R_s$ ( $\Omega/\square$ )
HEX125	2,7
HEX100	1,5
HEX075	1,5
TRI115	1,2
TRI087	0,82

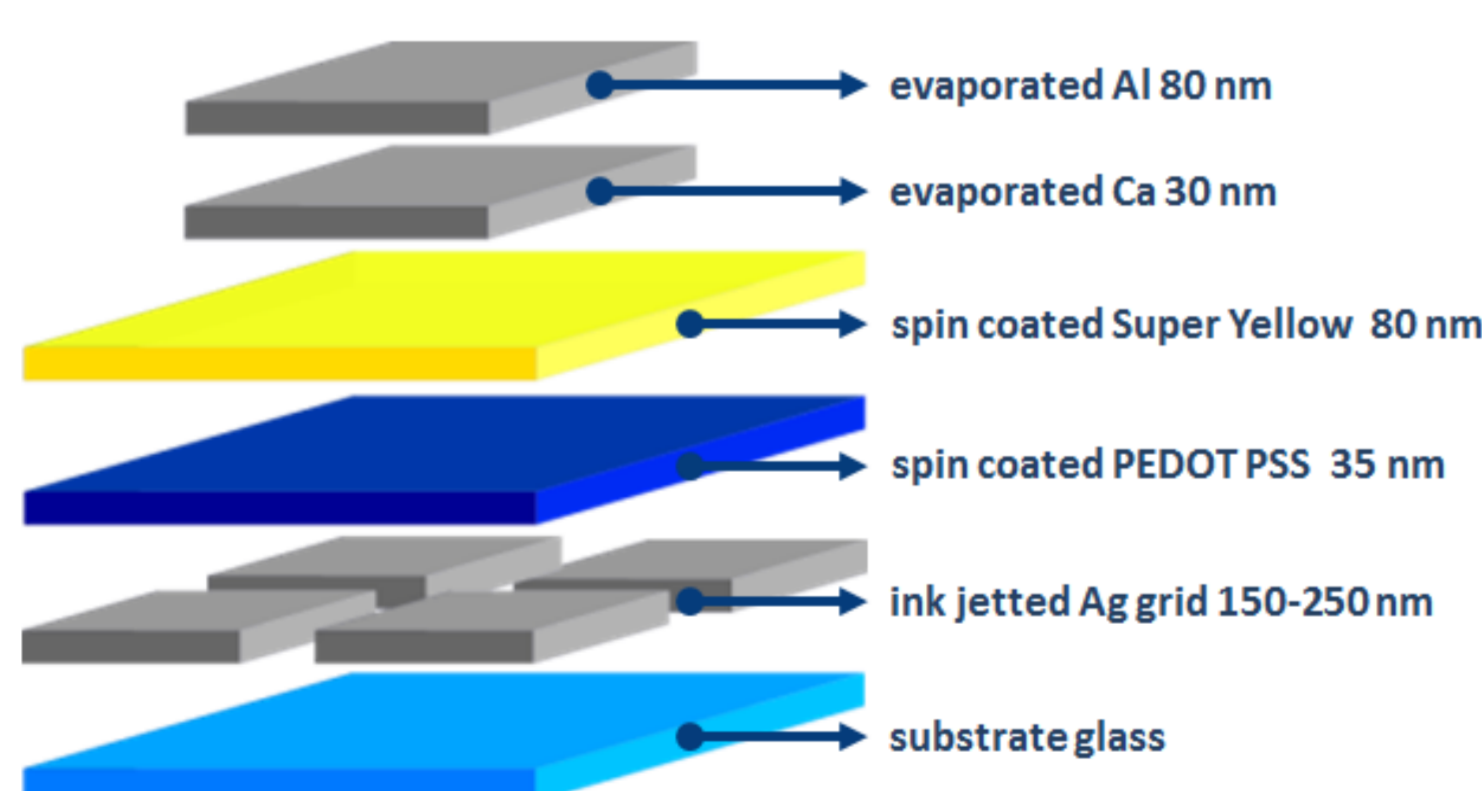
### Layer thickness

1-15 nm

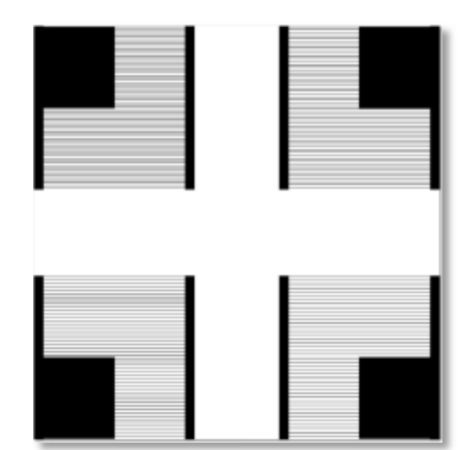
150-250 nm

## BEOLED with Ag grid

### Structure



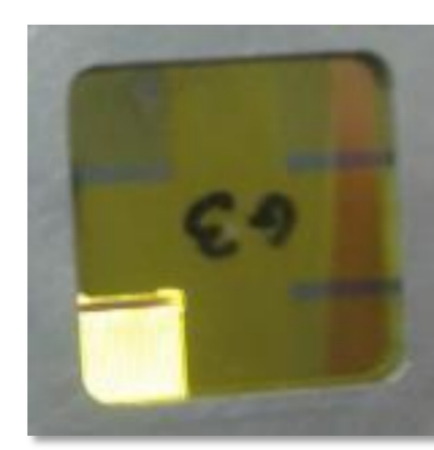
### Ag line grid



Patterned grid to prevent shorting  
Sintered at 200 °C

Problem with TEOLED!  
Other layers damaged by sintering! \*

### Working OLED



Lower light intensity and efficiency than ITO OLED

Optimization structure and thickness layers necessary!

## Conclusions

Au layers



Ag grids

Ag grids: - higher transmittance and conductivity  
- faster and less expensive technique (ink jet printing)

Au layers: - thinner and smoother layers

➔ Ag grids best option

### BEOLED with Ag grid

BEOLED with grid: - works  
- lower light intensity and efficiency than ITO OLED

➔ Optimization structure and thickness layers necessary

➔ Sintering Ag grid without damaging other layers TEOLED

\* For more information about sintering and ink jet printing, check out the poster 'Ink jet printing and sintering of silver patterns on several substrates' from Glen Vandevenne

### References

- [1] Y.C. Han et al. (2013), *Organic electronics*, 14 (12), pp 3437-3443  
[2] G.W. Hyung et al. (2012), *Journal of nanoscience and nanotechnology*, 12 (7), pp 5444-5448  
[3] Hong et al. (2013), *ACS Nano*, 7 (6), pp 5024-5031  
[4] Nalyeon, "Thermal evaporation" [Online]. Available: <http://marriott.tistory.com/73>  
[5] Image Permanence Institute, "Ink jet" [Online]. Available: <http://www.dp3project.org/technologies/digital-printing/inkjet>